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PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Attn: OIPE

Susumu NODA et al.

Application No.: 10/537,119

Docket No.: 123456

Filed: June 3, 2005

For: TWO-DIMENSIONAL PHOTONIC CRYSTAL SLAB HAVING THREE-DIMENSIONAL LOCAL STRUCTURE

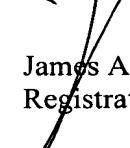
REQUEST FOR CORRECTION OF PALM RECORDS

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Attached is a photocopy of the original filing receipt on which errors have been corrected in red. These errors are being brought to the attention of the Patent and Trademark Office so that it may correct its records. The originally filed Application Data Sheet is attached.

Respectfully submitted,


James A. Oliff
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Jesse O. Collier
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JAO:JOC/mps

Date: December 13, 2005

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DEPOSIT ACCOUNT USE AUTHORIZATION Please grant any extension necessary for entry; Charge any fee due to our Deposit Account No. 15-0461
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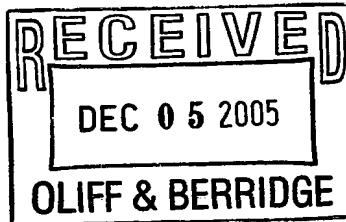
UNITED STATES PATENT AND TRADEMARK OFFICE

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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY.DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/537,119	06/15/2005	2874	1030	123456	6	14	3

CONFIRMATION NO. 8366

25944
OLIFF & BERRIDGE, PLC
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FILING RECEIPT



OC000000017546043

Date Mailed: 12/01/2005

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please mail to the Commissioner for Patents P.O. Box 1450 Alexandria Va 22313-1450. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s)

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Assignment For Published Patent Application

JAPAN SCIENCE AND TECHNOLOGY AGENCY, Kawaguchi-shi, JAPAN

Power of Attorney: The patent practitioners associated with Customer Number 25944.

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP03/15635 12/05/2003

Foreign Applications

JAPAN 2002-355631 12/06/2002

Projected Publication Date: 03/09/2006

Non-Publication Request: No

Early Publication Request: No

Title

THREE-DIMENSIONAL LOCAL STRUCTURE

Two-dimensional photonic crystal slab having local three-dimensional structure

Preliminary Class

385

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OLIFF & BERRIDGE, PLC
ATTORNEYS AT LAW

Application Data Sheet

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Correspondence Information

Correspondence Customer Number:: 25944

Application Information

Application Type::	National Phase
Subject Matter::	Utility
CD-ROM or CD-R::	None
Title::	TWO-DIMENSIONAL PHOTONIC CRYSTAL SLAB HAVING THREE-

DIMENSIONAL LOCAL STRUCTURE

Attorney Docket Number:: 123456
Suggested Drawing Figure::
Total Drawing Sheets:: 6
Small Entity:: No

Representative Information

Attorneys associated with Customer No. 25944.

Domestic Priority Information			
Application::	Continuity Type::	Parent Application::	Parent Filing Date::
This Application is a	National Stage of	PCT/JP03/015635	12/5/03
Foreign Priority Information			
Country::	Application Number::	Filing Date::	Priority Claimed::
JAPAN	2002-355631	12/6/02	Yes
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